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CONFIRMATION NO. 8489

SERIAL NUMBER	FILING OR 371(c) DATE	CLASS	GROUP ART UNIT	ATTORNEY DOCKET NO.	
10/646,467	08/22/2003	427	1762	006915/P6	
<b>RULE</b>					
<b>APPLICANTS</b> Kenneth S. Collins, San Jose, CA; Hiroji Hanawa, Sunnyvale, CA; Kartik Ramaswamy, Santa Clara, CA; Andrew Nguyen, San Jose, CA; Amir Al-Bayati, San Jose, CA; Biagio Gallo, Los Gatos, CA; Gonzalo Antonio Monroy, San Francisco, CA;					
<b>** CONTINUING DATA *****</b> This application is a CIP of 10/164,327 06/05/2002 PAT 6,939,434 which is a CIP of 09/636,435 08/11/2000 PAT 6,494,986					
<b>** FOREIGN APPLICATIONS *****</b> <i>None</i>					
<b>IF REQUIRED, FOREIGN FILING LICENSE GRANTED</b> <b>** 11/14/2003</b>					
Foreign Priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 (a-d) conditions <input type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after met Allowance Verified and Acknowledged <u>Examiner's Signature</u> <u>Initials</u>		<b>STATE OR COUNTRY</b> CA	<b>SHEETS DRAWING</b> 85	<b>TOTAL CLAIMS</b> 85	<b>INDEPENDENT CLAIMS</b> 1
<b>ADDRESS</b> Patent Counsel, M/S 2061 Legal Affairs Dept. Applied Materials, Inc. P.O. Box 450-A Santa Clara, CA95035					
<b>TITLE</b> Plasma immersion ion implantation process using an inductively coupled plasma source having low dissociation and low minimum plasma voltage					
<b>FILING FEE RECEIVED</b> 2090	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:		<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees ( Filing ) <input type="checkbox"/> 1.17 Fees ( Processing Ext. of time ) <input type="checkbox"/> 1.18 Fees ( Issue ) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit		